

Form 1449 (Modified)

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Serial No.:

Information Disclosure
Statement By Applicant

MAT-8

10/803,453

Applicants:

George, et al

Filing Date

Group

(Use Several Sheets if Necessary)

March 18, 2004

2821

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Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
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	2	4,252,608	2/24/1981	Baldwin et al			
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	22	Freisinger et al., "The neutral particle injectors RIG for fusion reactors", 1984, Atomkernenergie Kerntechnik, vol. 44 No. 1, pp. 81-86.
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Examiner		Date Considered
AC		4/10/07

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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Art Unit
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	E						
	F						
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Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
	H						Yes	No
	I							
	J							
	K							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
	L	
	M	
	N	
Examiner	Date Considered	
	4/10/07	

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



Form 2449 (Modified)

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U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
	A						
	B						
	C						
	D						
	E						
	F						
	G						

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Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub-class	Translation	
							Yes	No
	H							
	I							
	J							
	K							

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
AC	L	Two Drawings Labled "Helical Resonator Plasma Coater" Previously Cited and Reviewed for U. S. Patent Number 5,534,231.
AC	M	Techniques and Applications of Plasma Chemistry, 1974, John Wiley & Sons, pp 322-324
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Examiner		Date Considered
AC		4/10/02

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